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A DDI	ICANT:
AFFL	JUANI.

Won-Sung Choi

SERIAL NO.:

09/726,977

FILED:

November 30, 2000

FOR:

THIN FILM DEPOSITION APPARATUS

FOR SEMICONDUCTOR

BOX RCE

Assistant Commissioner for Patents

Washington, D.C. 20231

HEREBY CERTIFY THAT THIS CORRESPONDENCE E ADDRESSED TO:

ASSISTANT COMMISSIONER FOR PATENTS NASHINGTON, D. C. 20231

Group Art No.: 1763

Examiner:

Kackar, Ram N.

SUBMISSION UNDER 37 C.F.R. §1.114

This submission, in the form of an amendment with remarks, is filed under 37 C.F.R. §1.114 along with a Request for Continued Examination (RCE) and requisite fee. Grant of the Request, entry of the amendment, reconsideration of the claims, and allowance of the application are respectfully requested.

AMENDMENT

IN THE CLAIMS:

Please cancel claim 5, without prejudice.

Please replace claims 1-3, 6-13, 15 and 16 with the following claims rewritten in

clean form:

1. (Twice Amended) A semiconductor thin film deposition apparatus comprising: a reactor in which a wafer is received;

a reaction gas supply unit for providing reaction gas to the reactor;

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YPL-0014 (IP-15188-US)